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Physical properties of multiferroic hexagonal HoMnO_3 thin films

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The authors investigated the magnetic and ferroelectric properties of hexagonally grown HoMnO_3 thin films. The magnetic measurements revealed bulklike magnetic phase transitions with an additional spin-glass-like behavior feature below the Néel temperature. The ferroelectricity in the films was distinctly different from the suggested bulk behavior. Below 40 K, the HoMnO_3 films showed typical ferroelectric character: their remnant polarization and coercive field values at 20 K were $3.7 \mu\text{C}/\text{cm}^2$ and $0.69 \text{ MV}/\text{cm}$. Above 40 K, however, the films exhibited an unusual antiferroelectriclike behavior, with more pronounced features appearing at higher temperatures. These intriguing physical properties make HoMnO_3 films a potential candidate material for numerous future applications. © 2007 American Institute of Physics. [DOI: 10.1063/1.2718512]

Due to the complexity in their ferroelectric and magnetic ordering, studies on hexagonal manganites have continued since their discovery in the early 1960s.¹⁻¹⁰ Interest in the system was renewed with the finding that the magnetic phase in hexagonal HoMnO_3 crystals could be controlled by an external electric field.⁸ In hexagonal HoMnO_3 , the Mn^{3+} ion forms triangular lattices in the a - b plane, which are then stacked in alternating fashion along the c axis with Ho^{3+} layers in between.¹¹ At low temperature, the Mn^{3+} spins order antiferromagnetically at $T_N \approx 72 \text{ K}$ forming a noncollinear 120° spin structure in a $P6_3c'm$ magnetic symmetry.¹² Around 40 K,^{3,6,12} HoMnO_3 displays a spin reorientation transition, when the Mn^{3+} spins rotate 90° , resulting in a change in magnetic symmetry to $P6_3cm'$. At about 5 K, a second spin reorientation transition appears in the $P6_3cm$ magnetic symmetry, which is accompanied by a strong increase in Ho antiferromagnetic (AFM) ordering.^{3,13} Taken together, HoMnO_3 possesses a novel magnetic-field-induced reentrant phase with the most complex phase diagram of all hexagonal manganites.⁶

It was recently suggested that the origin of the ferroelectric distortion in hexagonal YMnO_3 is generated by the buckling of the MnO_5 polyhedral bonds accompanied by the displacement of the Y ions.⁷ Despite the extensive research on the magnetic and magnetoelectric properties of bulk HoMnO_3 , its ferroelectric properties have rarely been investigated. Although HoMnO_3 is reported to show a saturation polarization (P_s) of $5.6 \mu\text{C}/\text{cm}^2$ at a high Curie temperature ($\approx 875 \text{ K}$), most of our present understanding is based on limited older data.^{1,2} For this study, we fabricated epitaxial hexagonal HoMnO_3 thin films by pulsed laser deposition (PLD) techniques to conduct a comprehensive study of their magnetic and ferroelectric properties. Contrary to reported

bulk ferroelectric properties, our hexagonal HoMnO_3 films showed an interesting antiferroelectriclike (AFE-like) feature starting around 40 K.

HoMnO_3 films were deposited by the PLD method on Pt(111)/ $\text{Al}_2\text{O}_3(0001)$ and yttrium stabilized zirconia (111) [YSZ(111)] substrates. A sintered ceramic pellet of stoichiometric HoMnO_3 was used as a target for the PLD. Ablations were effected using a 248 nm wavelength KrF excimer laser (Lambda Physik) with fluence on target of 1.5 J cm^{-2} . To obtain high quality films, the substrate temperature and oxygen pressure were optimized at 850°C and 100 mTorr. Deposited film thickness was estimated to be around 100 nm. The crystal structure of the films was analyzed by high resolution x-ray diffraction. For the ferroelectric measurements, Au top electrodes of $100 \mu\text{m}$ diameter were sputtered through a shadow mask. The polarization hysteresis loops were measured using a low temperature probe station (Desert Cryogenics) and a T-F analyzer (aixACCT) at 2 kHz. The capacitance was measured using an LCR meter with an 50 mV, 100 kHz ac signal. Low temperature magnetization measurements were performed using a magnetic property measurement system (Quantum Design).

High quality epitaxial HoMnO_3 thin films were obtained under these optimized growth conditions. Figure 1(a) shows the x-ray diffraction (XRD) θ - 2θ patterns for the HoMnO_3 films on Pt(111)/ $\text{Al}_2\text{O}_3(0001)$ and YSZ(111) substrates. The patterns reveal pure (000 l)-oriented hexagonal HoMnO_3 reflections without a trace of an impurity or additional phases. To investigate the in-plane texture of the films, we measured the x-ray ϕ scans around the (1122) HoMnO_3 and (200) Pt reflections. As shown in Fig. 1(b), the ϕ scans of HoMnO_3 also display sixfold symmetry, suggesting epitaxial growth of the hexagonal HoMnO_3 film.¹⁰ From the XRD, we evaluated the in-plane (a) and out-of-plane (c) lattice parameters of the HoMnO_3 on Pt(111)/ $\text{Al}_2\text{O}_3(0001)$ to be 6.20 and 11.40 \AA , respectively. The respective values on YSZ(111) substrate are 6.15 and 11.37 \AA . The comparison with the bulk values

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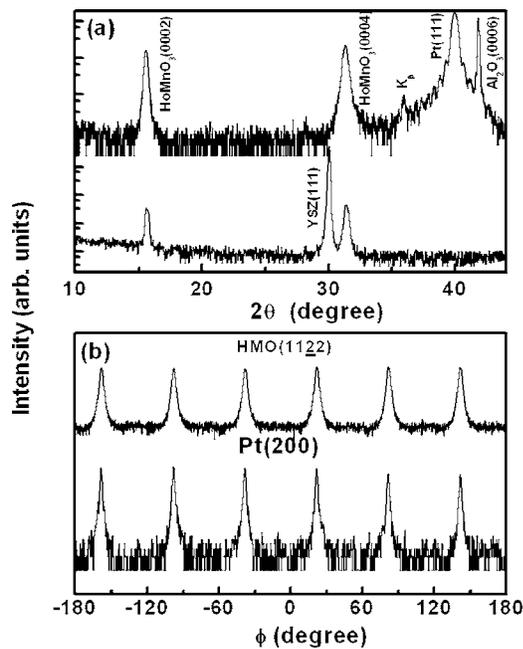


FIG. 1. (a) θ - 2θ XRD scans of HoMnO₃ films on Pt(111)||Al₂O₃ and YSZ(111) substrates. (b) ϕ scan plot of the HoMnO₃(1122) and Pt(200) reflections.

of $a=6.13$ Å and $c=11.40$ Å demonstrates that the HoMnO₃ films were grown under tensile strained condition. Note that the c lattice parameter of the film on Pt(111)/Al₂O₃(0001) substrate remains the same as the bulk value, indicating a possible oxygen nonstoichiometry of the film.

In the magnetic property studies, the magnetic background signal from the Pt/Al₂O₃ substrate was found to be very large.¹⁰ Therefore, we epitaxially deposited the HoMnO₃ films on an YSZ(111) substrate rather than on Pt(111)/Al₂O₃(0001). Figure 2 shows the magnetization versus temperature curves measured under the zero-field cooled (ZFC) and the field cooled (FC) conditions. Both curves show anomalies near 50 and 38 K. These anomalies are clearly seen in the inverse susceptibility versus temperature ($1/\chi$ vs T) plot of the ZFC data shown as solid squares in Fig. 2. The inverse susceptibility undergoes a sharp decrease at ~ 70 K, reaching a first minimum at 50 K followed by another at 38 K. The 50 K minimum could have originated

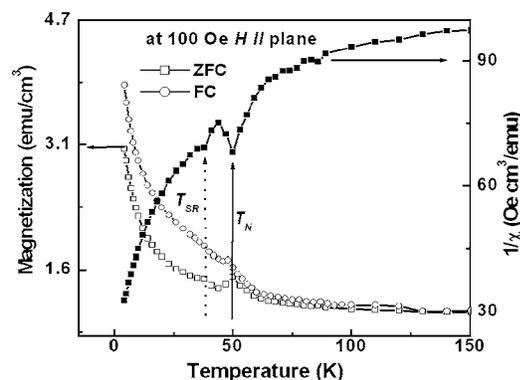


FIG. 2. (a) Magnetization vs temperature plot of a HoMnO₃ film on a YSZ(111) substrate, measured under zero-field cooled condition (open squares) and a 100 Oe field cooled condition (open circles). The solid squares represent the inverse susceptibility vs temperature plot measured under a zero-field cooled condition.

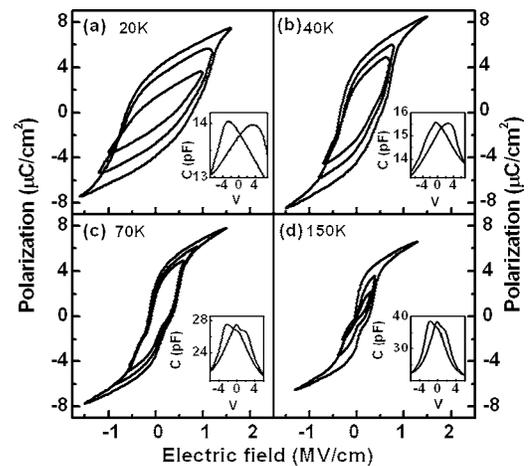


FIG. 3. Polarization vs electric field hysteresis loops for a HoMnO₃ film measured at (a) 125 K, (b) 40 K, (c) 70 K, and (d) 150 K. The inset shows the capacitance vs voltage plot measured at the same temperatures.

from the AFM ordering of the Mn³⁺ spins in their triangular lattice, while the 38 K could have come from the Mn³⁺ spin reorientation transition. In addition, the steep fall in $1/\chi$ below 10 K may be attributable to the Ho³⁺ spin ordering.

When compared to its bulk counterpart, the HoMnO₃ films exhibited interesting magnetic properties. First, the AFM ordering temperature T_N of our film is about 50 K, significantly lower than the corresponding bulk value of 72 K. However, the spin reorientation temperature T_{SR} of our film is similar to that of the reported bulk value, i.e., about 40 K. Fiebig *et al.* stated that the AFM ordering of the Mn³⁺ spin comes from the in-plane exchange interaction and that the spin reorientation could be attributed to the magnetic superexchange interaction between the Mn³⁺ and the Ho³⁺ spins along the c axis.¹⁴ Tensile stress, applied to the HoMnO₃ film, can lower the exchange interaction and hence T_N . However, it will not affect the c -axis magnetic interaction significantly, causing little change in T_{SR} . Second, the HoMnO₃ film shows a spin-glass-like behavior below T_N , as seen in the hysteresis between the ZFC and FC magnetization data shown in Fig. 2. Munoz *et al.* reported no difference between the ZFC and FC susceptibilities in bulk HoMnO₃ polycrystalline samples.³ Although the spin-glass-like behavior could be related to the geometrical frustration of antiferromagnetically coupled Mn³⁺ spins, it is not yet clear why our film's magnetic susceptibility data are so different from the reported bulk behavior.

The electric properties of the hexagonal HoMnO₃ films also display surprisingly different behavior than the accepted view that HoMnO₃ has a ferroelectric phase with a P_s of 5.6 $\mu\text{C}/\text{cm}^2$ and a very high Curie temperature of about 875 K.^{1,2} We measured the polarization versus electric field (P - E) hysteresis loops between 4 and 220 K (leakage current problems around room temperature, due to possible oxygen nonstoichiometry, prevented higher temperature measurements). Figures 3(a)–3(d) show the P - E loops measured at 20, 40, 70, and 150 K, respectively, for several values of maximum applied E . All of the P - E hysteresis loops show nearly saturating behaviors, indicating that the leakage current provides negligible contributions below 150 K. At 20 K, the P - E loops indicate a clear ferroelectric hysteresis character with remnant polarization (P_r) and coercive field (E_c) values of 3.7 $\mu\text{C}/\text{cm}^2$ and 0.69 MV/cm. Surprisingly, above

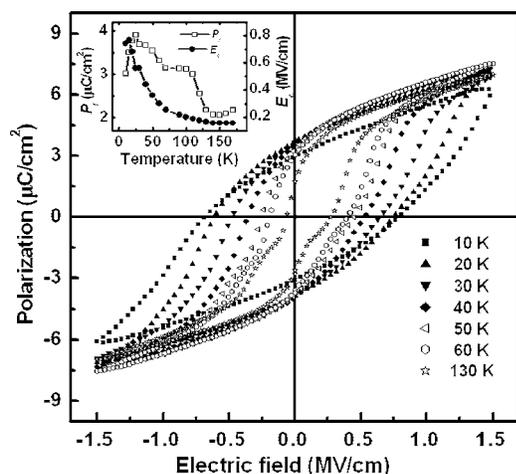


FIG. 4. Polarization vs electric field hysteresis loops for a HoMnO_3 film measured at various temperatures. The inset shows the temperature dependence of the remnant polarization and coercive field.

40 K, the P - E loops appear different from conventional ferroelectric loops. In particular, at 70 K, the P - E loop shows an AFE-like shape whose features become clearer with increasing T .

Figure 4 shows the systematic development of the AFE-like feature with increasing temperature. To prevent dielectric breakdown, the maximum applied field was limited to 1.5 MV/cm above 30 K, when the P - E hysteresis loops showed saturation. The inset of Fig. 4 presents the P_r and E_C values plotted against T . Apart from the sharp decrease in P_r due to the unsaturated P - E loop below 30 K, both the P_r and E_C trends became higher with decreasing T . The increase in E_C might be explained in terms of an increase in domain pinning effects at low temperature.^{15,16} However, the AFE-like behavior in our HoMnO_3 films could not be attributed to these domain pinning effects because then the AFE-like behavior should be stronger at lower temperature, contrary to our observations. In addition, the unusual AFE-like properties are further demonstrated in the double butterfly-shaped capacitance versus electric field loops shown in the insets of the respective graphs in Fig. 3.

We believe that, with the exception of YMnO_3 , complete P - E loop data are not available for either bulk or thin films of hexagonal manganites. The P - E loop for the hexagonal YMnO_3 film shows a typical ferroelectric response. As the ionic sizes of Y^{3+} and Ho^{3+} ions are quite similar, the AFE-like behavior in our HoMnO_3 films is quite unexpected. However, the lack of available data on bulk HoMnO_3 makes it difficult to conclude that the observed AFE-like properties are unique to the HoMnO_3 thin films.

Using epitaxial stabilization techniques,^{10,17} we were recently able to fabricate hexagonal TbMnO_3 and DyMnO_3 films, with their orthorhombic equilibrium phases. In these

artificial materials, we observed similar AFE-like properties. Note that the Y^{3+} ions do not have spin, but that the Ho^{3+} , Dy^{3+} , and Tb^{3+} ions do. The observation of the AFE-like behavior only for films with magnetic spins is quite intriguing and strongly supports further systematic investigations.

In summary, good quality epitaxial hexagonal HoMnO_3 films were fabricated on both $\text{Pt}(111)/\text{Al}_2\text{O}_3(0001)$ and $\text{YSZ}(111)$ substrates. At low temperatures, the films revealed several magnetic transitions, including antiferromagnetic, spin reorientation, and Ho^{3+} ordering transitions displayed in order with decreasing temperature. The HoMnO_3 films differ from the bulk material in both a significantly lower Néel temperature and in a spin-glass-like behavior. In addition, contrary to general belief, the HoMnO_3 films showed anti-ferroelectriclike features starting at 40 K. The present work strongly promotes the need for better understanding of these hexagonal manganite thin films, which could lead to novel applications for these materials.

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